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exposing the nitrogen-bearing molecule and plasma [ molecule ] gas to microwave energy, therein generating an emission of light from the plasma [ molecule ] gas within the chamber,

exposing the nitrogen-bearing molecule to the emission of light from the plasma [ molecule ] gas, thereby disassociating a nitrogen ion from the nitrogen-bearing molecule; and

placing the nitrogen ion in close proximity to a Group III receptor ion, such that the Group III receptor ion and the nitrogen ion combine to form a nitride on the substrate.

- The method of claim 1, wherein the nitrogen-bearing molecule is ammonia.
- The method of claim 1, wherein the receptor ion is 3. selected from the group consisting essentially of:

aluminum;

gallium; and

indium.



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4. The method of claim 1, where the receptor ion is an alloy of a Group III element.

5. (Amended) A method of creating a layer on a substrate, comprising the steps of:

placing a substrate having a top in a chamber;

generating an excitation beam within the chamber whereby a direction of the excitation beam is substantially perpendicularly directed toward the top of the substrate;

introducing a <u>nitrogen-bearing</u> reactant gas that flows into the excitation beam thereby generating a plasma;

introducing an inert gas selected from the group consisting of argon, neon, mercury, and xenon into the excitation beam [ and the reactant gas ] thereby generating ultraviolet light, wherein the ultraviolet light assists in dissociating the nitrogen bearing reactant gas;

flowing [an ionic] the nitrogen-bearing reactant gas into the chamber across the top of the substrate, whereby the plasma interacts with the [ionic] nitrogen-bearing reactant gas; and

flowing a group III gas into the chamber across the top of the substrate, whereby the plasma interacts with the group III

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gas, and whereby the interaction of the plasma with the [ ionic ] nitrogen-bearing reactant gas and the group III gas causes a growth of a group III nitride layer on the substrate.

(Amended) The method of claim 5, wherein the nitrogenbearing reactant gas is selected from a group consisting of ammonia and a mixture of ammonia and nitrogen.

The method of claim 5, wherein the group III gas is gallium.

The method of claim 5, wherein the group III gas is a combination of gallium and indium.

#### REMARKS

#### Introduction L

In response to the Office Action of June 26, 1997, and in response to the telephone interviews with the Examiner on November 5, 1997, claims 1, 5, and 6 have been amended, and claims 7, 8, and 17-20 has been cancelled without prejudice.